	A Clean)	Dry	15 min		÷			
	c clean (RC	Rinsc	8 min		Ş			
	Wet Bench: oxide etch + hydrophilic clean (RCA clean)	SC2	10 m (n	64 min Total	Single Water Cleaning Tool Single Step Clean Oxide etch + hydrophilic clean	40	20sec	
		Rinse	\& \\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\			Rinse	20sec	
In the present the second seco		SCI	lomin			Chemica (Clean	30sec	-2 min Total -
		Rinse	8 mis			Rinse	20sec	
	Figure 1 A	HF Etch	رة ية	*	Figure 7.6	HF E+Ch	30 sec	

Figure 2 a

$$\frac{100^{-1} - C + 2}{(-):N - CH_2 - CH_2 - CH_2 - N:(-)}$$

$$\frac{100^{-1} - C + 2}{0} - C - CH_2$$

$$\frac{100^{-1} - C + 2}{0} - C + 2$$

$$\frac{100^{-1} - C + 2}{0} - C + 2$$

$$\frac{100^{-1} - C + 2}{0} - C + 2$$

$$\frac{100^{-1} - C + 2}{0} - C + 2$$

$$\frac{100^{-1} - C + 2}{0} - C + 2$$

$$\frac{100^{-1} - C + 2}{0} - C + 2$$

$$\frac{100^{-1} - C + 2}{0} - C + 2$$

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$$\frac{100^{-1} - C + 2}{0} - C + 2$$

$$\frac{100^{-1} - C + 2}{0} - C + 2$$

$$\frac{100^{-1} - C + 2}{0} - C + 2$$

$$\frac{100^{-1} - C + 2}{0} - C + 2$$

Binds Metal ions

Figure 26

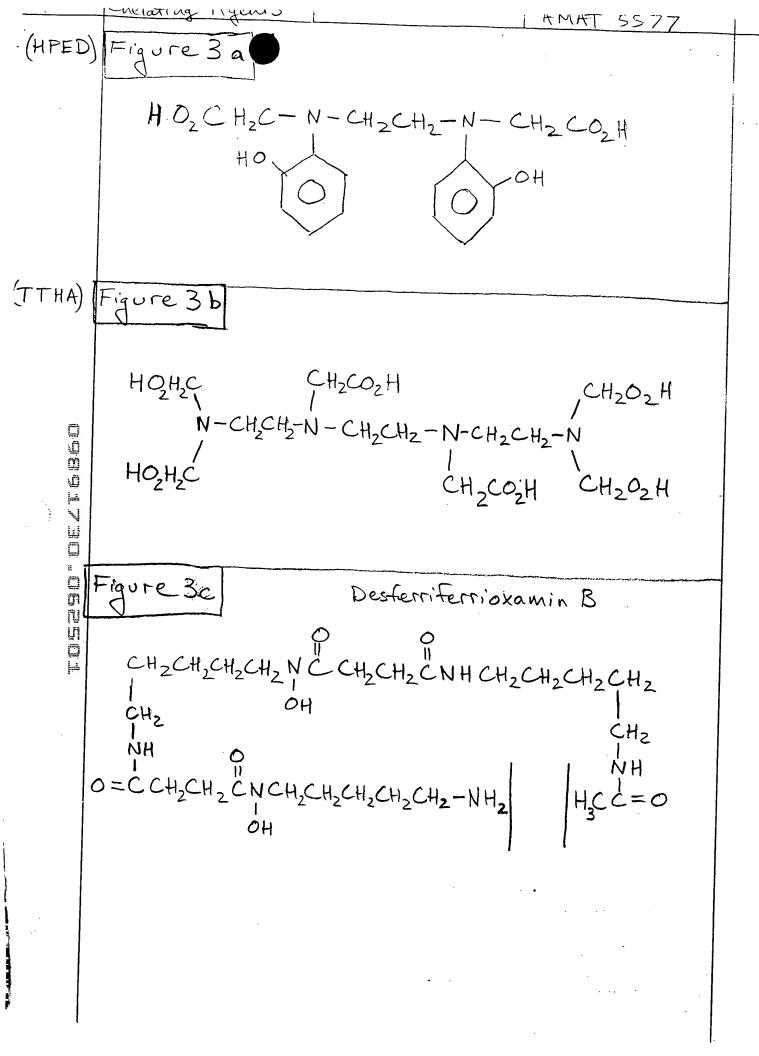
-igure

NFH-0-C-CH2

NX+-N-CH2-CH2-N-(MX)

(MX+)-N-CH2-CH2-N-(MX)

(CH2-C-0-(MX+1)+
0



COESTYSO CHEST

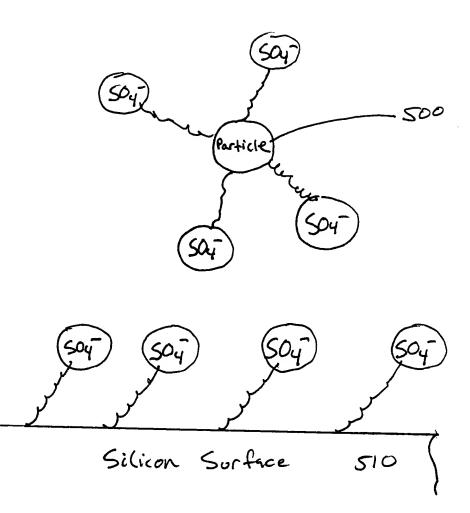


Figure ba

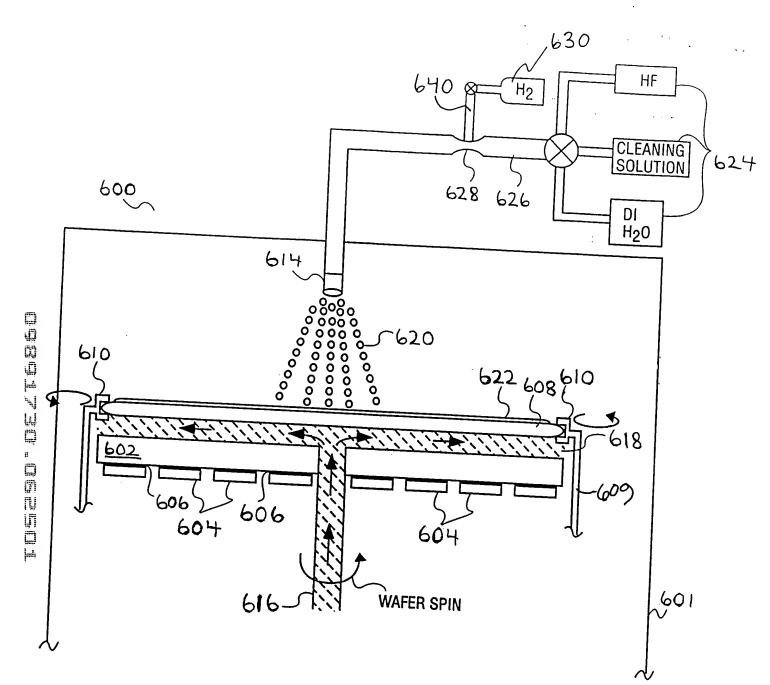
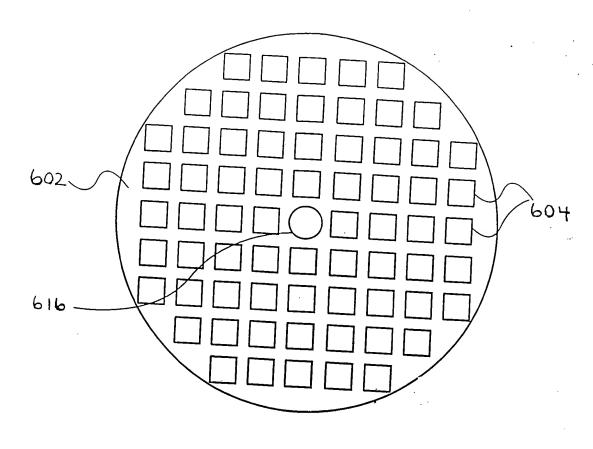


Figure 6b



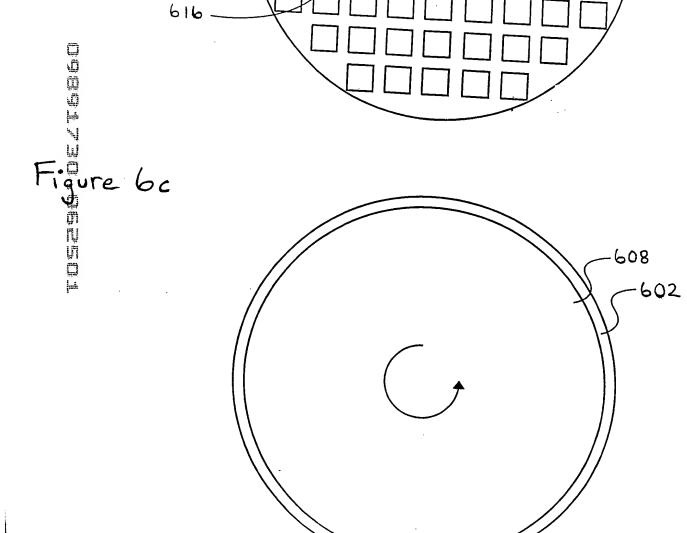
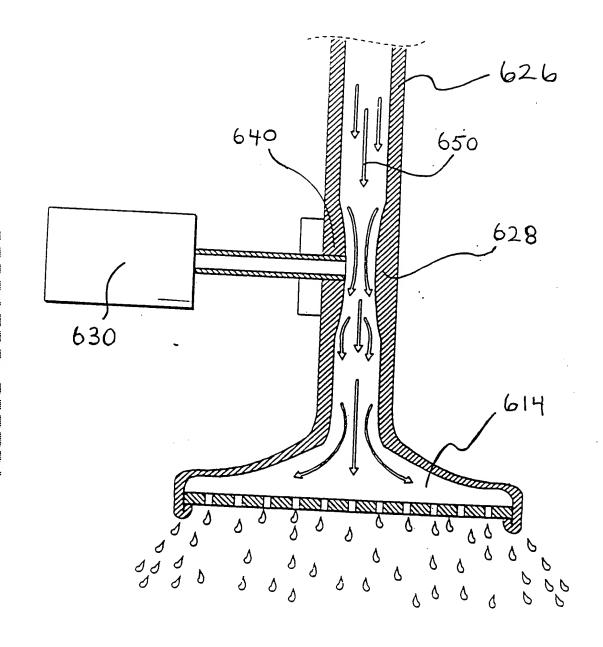
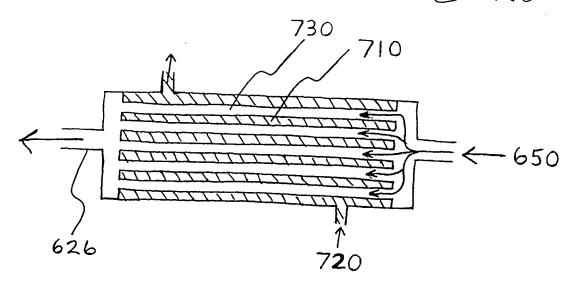


Figure 6d



FORMU, OKKINGE



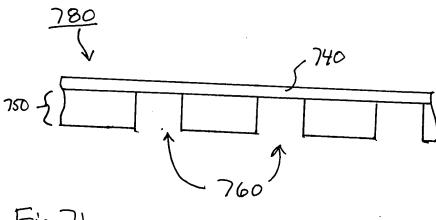
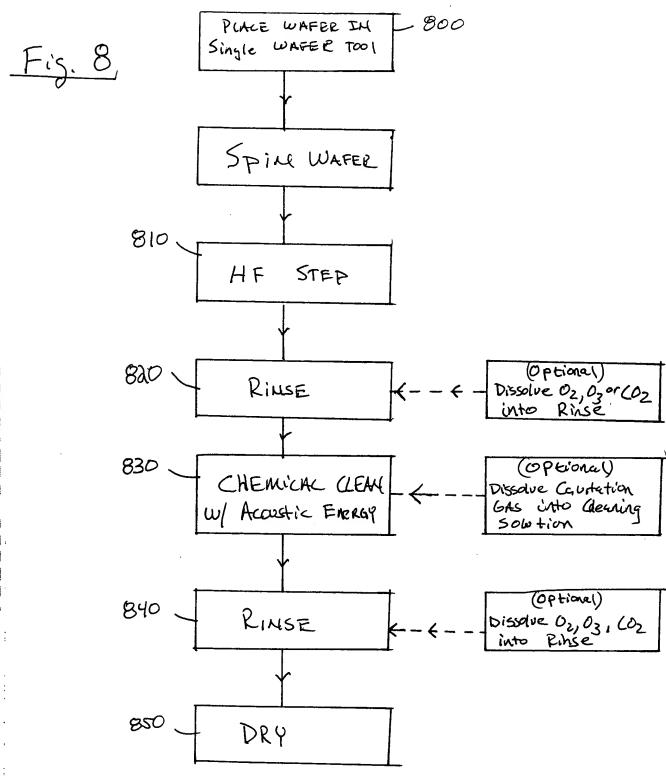


Fig.7b

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